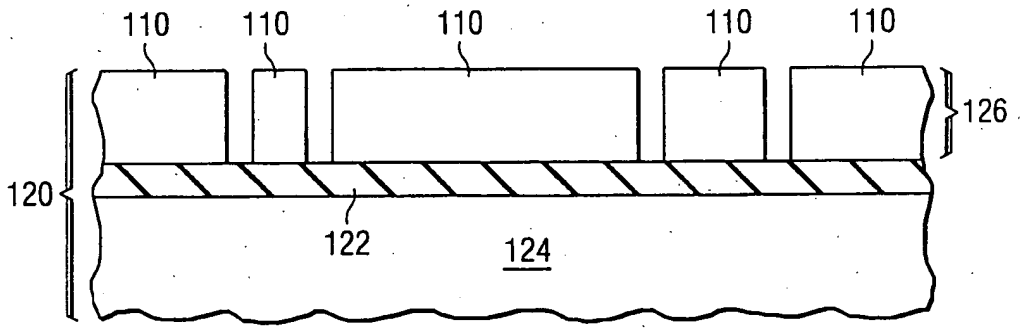

Fig. 1

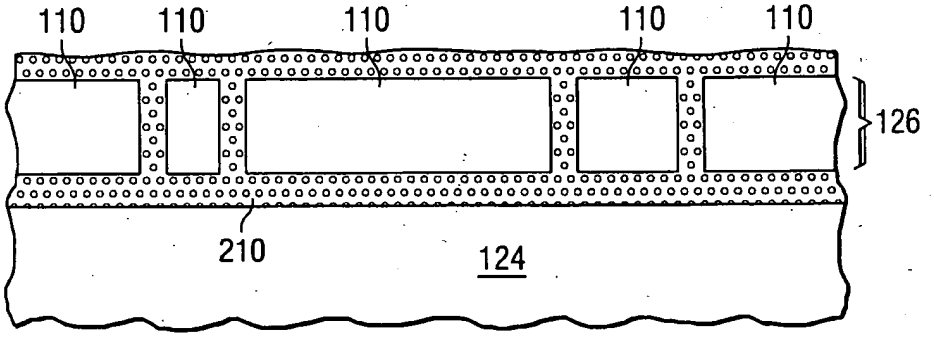

Fig. 2

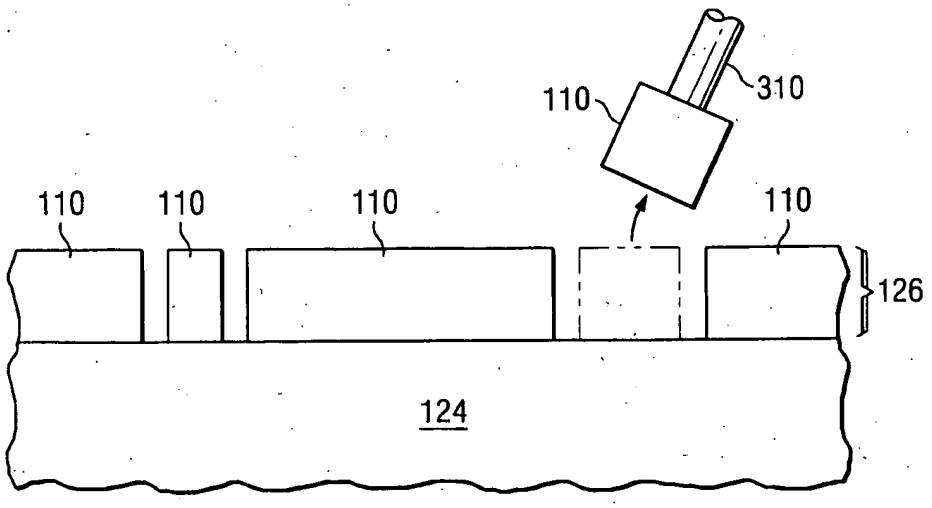

Fig. 3

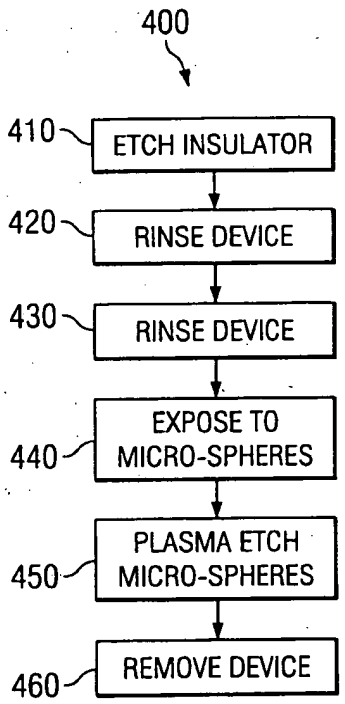
400
410
ETCH INSULATOR
420
RINSE DEVICE
430
RINSE DEVICE
440
EXPOSE TO MICRO-SPHERES
450
PLASMA ETCH MICRO-SPHERES
460
REMOVE DEVICE

Fig. 4

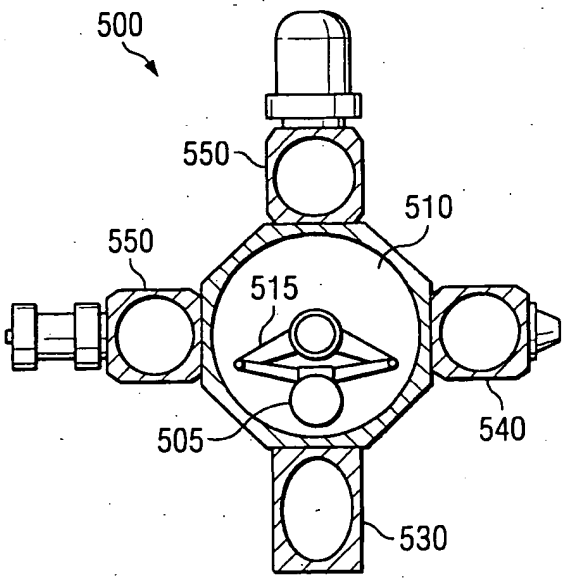
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Fig. 5